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Spatial modulation of the Dirac gap in epitaxial graphene

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ABSTRACT

We use scanning tunneling spectroscopy (STS) at low temperatures to investigate the local electronic structure of mono- and bilayer graphene grown epitaxially on SiC(0001). Already for monolayer graphene, a gap opening is observed in the π -bands at the Dirac point. The gap size is spatially modulated with the $(6\sqrt{3} \times 6\sqrt{3})R30^\circ$ periodicity of the interface structure. We ascribe this effect to a spatially dependent interface potential, which is imprinted into the graphene layer. For bilayer graphene the Dirac gap has a constant size, but a spatially localized mid-gap state is observed within. For both, gap state and π -bands the intensities are strongly modulated with the atomic periodicity of graphene.

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Flat layers of sp^2 -bonded carbon are the basic building block of graphite. As individual free-standing layers they are well-known under the name graphene. Graphene displays unconventional electronic properties [1] which make it a highly promising candidate for the realization of nano-electronic circuits [2]. In particular, monolayer graphene exhibits a linear electronic dispersion of the π -bands near the so-called Dirac point [3]. Electrons can be viewed as massless and relativistic and possess a large velocity equal to 1/300 of the speed of light. The successful preparation of single- and multilayers of graphene was first realized by mechanical exfoliation generating micron sized flakes [4,5]. For a practical application, however, the ability to prepare graphene on a large scale and supported on a substrate would be of advantage. Besides first successful approaches based on the reduction of graphene oxide [6], the epitaxial growth of graphene on hexagonal SiC surfaces by thermal decomposition of the topmost SiC bilayers of the substrate is very promising in this respect [7]. On SiC(0001), mono- and few-layer graphene can be successfully grown in a controlled manner [7–10]. The number of graphene layers grown in this fashion determines the splitting into different branches of the π -bands crossing the Dirac point [11,12].

For a slab of two layers of graphene, the opening of a gap at the Dirac point is expected [11] and indeed found experimentally [12,13]. Yet, the exact size of the gap, its position in the energy diagram, and in particular whether this gap opens also for a single graphene layer, are currently disputed. Using angle-resolved photoemission spectroscopy (ARPES) Bostwick et al. found that no gap exists for monolayer graphene [14], while in a different

experiment with the same method a gap was discovered already for the first graphene layer [13]. It is important to understand the electronic structure and possible presence of a gap in this regime for epitaxial graphene since it has an important impact on potential applications such as field effect devices. In the present paper we use scanning tunneling spectroscopy (STS) to investigate the electronic structure of epitaxial graphene with high spatial resolution and demonstrate the presence of a gap already for monolayer graphene.

According to theoretical predictions, the opening of a gap in the π -band dispersion can be caused by different effects. Symmetry breaking within the graphene layers affects the band structure and induces a gap in the local density of states (LDOS) at the Dirac energy [15,16]. In particular, an interlayer stacking sequence such as, for instance, Bernal AB stacking, leads to a non-equivalency of the two carbon atoms in the graphene unit cell. This type of symmetry breaking within the graphene unit cell induced by the substrate-graphene stacking was suggested to explain the gap observed in the monolayer [13]. An additional symmetry breaking in epitaxial graphene can originate from a charge transfer between the first graphene layers and the substrate. The charge accumulation at the interface creates a dipole potential, whereby the effect is reduced by screening in additionally grown layers. As a consequence the first few layers of epitaxial graphene are not equivalent with respect to charge and electrostatic potential. The sensitivity of the electronic structure in graphene to such an electrostatic potential has been demonstrated by the successful control of the gap size by depositing electron-donor impurities (K atoms) on the graphene surface [9].

The lattice mismatch between graphene and the SiC substrate gives rise to a complex atomic structure of the interface in epitaxial

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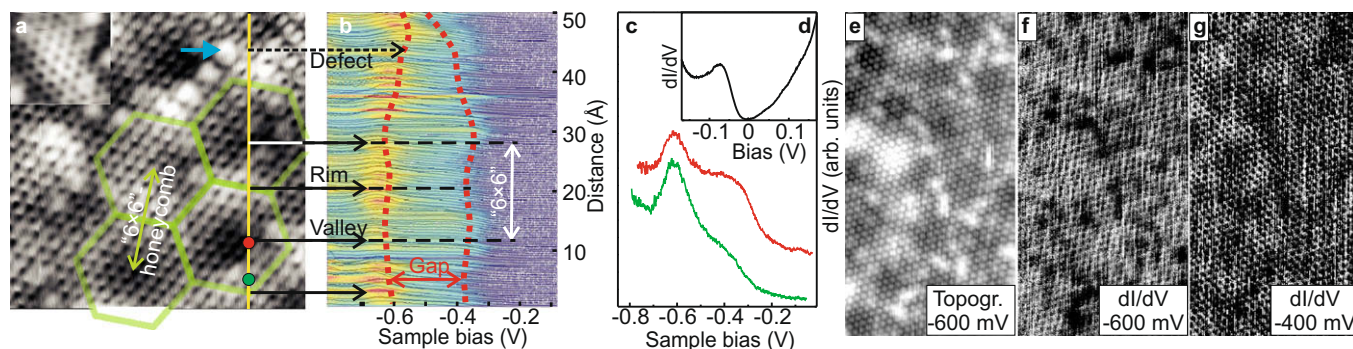


Fig. 1. Monolayer graphene: (a) Topographic region (image size $50 \text{ \AA} \times 50 \text{ \AA}$, sample bias 100 mV, 0.5 nA, inset at 440 mV). The green hexagons indicate the quasi-“(6 × 6)” periodicity. (b) Color scale plot of dI/dV spectra obtained along the yellow line in (a). The dashed lines mark the positions of the π -band onsets as a guide to the eye. (c) Selected dI/dV spectra obtained on the positions marked with a dot in (a) displayed with a vertical shift for better visualization. (d) dI/dV Spectrum at the Fermi energy. (e–g) Topographic image and conductance maps (image size $100 \text{ \AA} \times 50 \text{ \AA}$) simultaneously measured at the energy of the π -band onset. (For interpretation of the references to colour in this figure legend, the reader is referred to the web version of this article.)

graphene. This is quite obvious from its large commensurate unit cell with a $(6\sqrt{3} \times 6\sqrt{3})R30^\circ$ periodicity as seen in low-energy electron diffraction (LEED) [10,17,18]. The interface is formed by the first carbon layer evolving in the annealing process, which does not yet possess a linear π -band dispersion at the Dirac point and rather acts like a buffer layer [19]. Only the next carbon layer has typical graphene properties and corresponds to a graphene monolayer. Further heating then leads to bilayer graphene. The nature of the interfacial buffer layer must have a significant electronic influence on the subsequent layers, since it has a strong and bias dependent electronic corrugation as seen in scanning tunneling microscopy (STM). Under most conditions it is imaged as a quasi-“(6 × 6)” pattern characterized by a honeycomb or hillock structure [20,21]. Only at certain bias values its true $(6\sqrt{3} \times 6\sqrt{3})R30^\circ$ periodicity is observed [10]. The aim of the present work is to investigate the influence of this spatially strongly modulated electronic structure on the dispersion of the π -bands in the epitaxial graphene layers. For this purpose we measure the LDOS of graphene grown on SiC with high spatial resolution using STS at low temperatures.

Samples, cut from a 4H-SiC(0001) wafer,¹ were hydrogen etched for the removal of polishing damage [22]. In order to enable a homogeneous graphene growth [10], Si deposition and annealing steps were taken in ultra-high vacuum (UHV), first to the Si-rich (3×3) phase [23] and then to a well-ordered $(\sqrt{3} \times \sqrt{3})R30^\circ$ Si adatom reconstruction [24]. The $(6\sqrt{3} \times 6\sqrt{3})R30^\circ$ periodic buffer layer was obtained by annealing to temperatures above 1150 °C [10]. Graphene layers were then generated by annealing at even higher temperature. Their thickness was characterized by LEED [10,28]. The prepared graphene sample was then transferred ex situ to the STM chamber. In UHV the sample was again annealed up to 1050 K in order to desorb impurities. The topographic and spectroscopic measurements were conducted with a UHV–STM at a temperature of ≈ 6 K.

An STM topographic image of a graphene monolayer is shown in Fig. 1a. It shows the graphene structure superimposed onto the periodicity of the underlying buffer layer in agreement with previous reports [10,25–27]. The structure of the buffer layer can be seen through the graphene grid as a honeycomb shaped wall structure as indicated by the green hexagons. The typical terrace width is at least 200 Å. In panel c, dI/dV spectra are shown for the positions marked with dots in panel a. All spectra exhibit two peaks at energies close to the Dirac point, which can be attributed to the onsets of the π -bands. This indicates that the π -bands

are separated by an energy gap. The Dirac point as determined by the median of the two band onsets is shifted with respect to the Fermi level (E_F) by about –460 mV, which is in agreement with reported [12,13] and home laboratory ARPES measurements [28]. The observation of a gap opening for monolayer graphene is in contrast to Ohta et al. [9] but in accordance with Zhou et al. [13]. However, the gap can not simply be due to an AB asymmetry of the two atoms per unit cell caused by a Bernal-type stacking with respect to the buffer layer [25,26,29] as all six atoms of the hexagonal honeycomb of graphene are retrieved (inset in panel a).

Most importantly, our STM measurements reveal that the peak positions vary in energy according to the periodicity of the interface structure. The modulation of the Dirac gap is visualized in Fig. 1b. It shows in a color scale map the dI/dV spectra measured along the yellow line marked in panel a.² The positions of the π -band onsets (red dashed lines) vary smoothly and fluctuate with the quasi-“(6 × 6)” periodicity (green hexagons) of the buffer layer. The average value of the gap is 220 mV with a modulation around the Dirac energy of about ± 40 mV between valley (maximum) and rim (minimum) positions. Still, the Dirac energy remains constant except in close proximity to defects (blue arrow in Fig. 1a) [26,30]. Here, also the gap is significantly reduced. For completeness also the dI/dV spectrum at the Fermi energy on the monolayer is shown in panel d. The observed line shape demonstrates the (still not understood) electronic DOS of epitaxial graphene, previously reported [25,27].

In order to understand the possible origin of the spatially modulated Dirac gap, energy resolved conductance maps at the π -band onsets were obtained by recording the dI/dV signal at the corresponding bias values (see Fig. 1). Together with a topographic map (panel e), they are shown in panel f and g. The impact of the buffer layer structure on the graphene monolayer is evident. At –400 mV a modulating potential with a quasi-“(6 × 6)” periodicity is superimposed onto the structure of the graphene monolayer (panel g). At –600 mV dark dots (points of lower conductance) can be seen (panel f). The absence of electronic scattering around them excludes their origin to be from adsorbed impurities on the graphene layer. At the first glance these dots do not seem to form an ordered pattern. However, by superimposing the topographic image onto the conductance map the dots can be correlated with the bright atom-like features in the quasi-“(6 × 6)” honeycomb pattern of the buffer layer. This suggests that

² The dI/dV spectra and the energy resolved conductance maps reported in this letter have been recorded by means of a lock-in technique applying a sample bias modulation in the range of 10–15 mV.

¹ Resistivity: 0.017 Ω cm, n-type, N doped.

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